

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L15	59	438/306.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 11:39
L14	459	438/305.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 11:39
L13	136	438/232.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:59
L12	185	438/231.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:47
L11	52	438/230.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:33
L8	100	438/163.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:23
L7	96	gate and source and drain and (sidewall or side adj wall or gate) near2 (spacer) near3 (plural or plurality or secondary or second or multi or multiple) and spacer near4 (implant or implanting or implanted) near5 (ldd or graded near3 drain or lightly near doped near2 (source or drain))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:15
L6	737	gate and source and drain and (sidewall or side adj wall or gate) near2 (spacer) near3 (plural or plurality or secondary or second or multi or multiple) and spacer near4 (implant or implanting or implanted)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:04
L5	102	gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and (sidewall or side adj wall or spacer) near4 (implant or implanting or implanted) near5 (aligned or alignment or aligning)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 10:03
L4	528	gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and (sidewall or side adj wall or spacer) near4 (implant or implanting or implanted)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 09:51
S11	600	gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and sidewall near4 (doping or doped or dopant or implant or implanting or implanted or impurity or aligned or alignment)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 09:50
S16	27	((multiple near implant\$2) near2 (ldd or lightly near doped near drain) or mildd)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 09:48

L3	34	((multiple near implant\$2) near2 (ldd or lightly near doped near drain) or mildd)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 09:48
L2	11	("5460993"   "5637514"   "5641698"   "5719425"   "5789298"   "5866460"   "5963814"   "5966611"   "5970358"   "5998274"   "6140186").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/08/11 09:24
L1	59	"5132757".pn. "6083846".pn. "6258680".pn. "5766969".pn. "6127212".pn. US-5348900-\$.DID. OR US-5460993-\$.DID. OR US-5637514-\$.DID. OR US-5641698-\$.DID. OR US-5719425-\$.DID. OR US-5789298-\$.DID. OR US-5866460-\$.DID. OR US-5920782-\$.DID. OR US-5963814-\$.DID. OR US-5966611-\$.DID. OR US-5970358-\$.DID. OR US-5998274-\$.DID. US-5981345-\$.DID. OR US-6124614-\$.DID. OR US-6140186-\$.DID. OR US-6187645-\$.DID. OR US-6261913-\$.DID. OR US-6350665-\$.DID. OR US-6383881-\$.DID. OR US-6448143-\$.DID. OR US-6635540-\$.DID. "5376566".pn. "5382533".pn. "5393683".pn. "5405791".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/11 09:10
S32	2	"6635540".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/02 15:11
S31	34	((multiple near implant\$2) near2 (ldd or lightly near doped near drain) or mildd)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/02 15:11